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L6 and (anneal\$ same (chloride or chlorine or HCl or hydrochloric or halogen))	20

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result set*DB=USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ*

<u>L7</u>	L6 and (anneal\$ same (chloride or chlorine or HCl or hydrochloric or halogen))	20	<u>L7</u>
<u>L6</u>	(438/774 OR 438/241 OR 438/296).CCLS.	1201	<u>L6</u>
<u>L5</u>	L1 and ((dual or multiple) near4 gate oxide same (chloride or chlorine or HCl or hydrochloric or halogen))	2	<u>L5</u>
<u>L4</u>	L1 and (anneal\$ same gate oxide same (chloride or chlorine or HCl or hydrochloric or halogen))	69	<u>L4</u>
<u>L3</u>	L1 and (anneal\$ near8 gate oxide near12 (chloride or chlorine or HCl or hydrochloric or halogen))	2	<u>L3</u>
<u>L2</u>	L1 and (form\$ near6 gate oxide near10 (chloride or chlorine or HCl or hydrochloric or halogen))	13	<u>L2</u>
<u>L1</u>	((438/\$).ccls.)	145296	<u>L1</u>

END OF SEARCH HISTORY